

Evaluation of Photocatalysts for Water Splitting through Combined Analysis of Surface Coverage and Energy-Level Alignment

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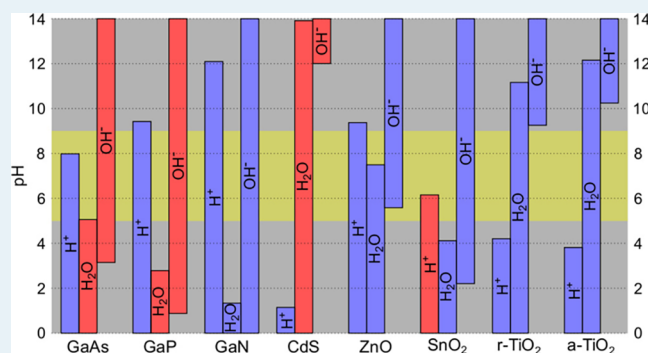
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ABSTRACT: To examine whether suitable conditions occur for the water splitting reaction at their interfaces with liquid water, we determine the pH-dependent surface coverage for a series of semiconductors, including GaAs, GaP, GaN, CdS, ZnO, SnO₂, and rutile and anatase TiO₂. For this, we calculate acidity constants at surface sites through ab initio molecular dynamics simulations and a Grand Canonical formulation of adsorbates. The resulting pH values at the point of zero charge show excellent agreement with experiment and thereby support the validity of our approach. By combining information concerning the surface coverage with the alignment of the band edges with respect to the relevant redox levels, we scrutinize the potential of the considered semiconductors as photocatalysts and identify the corresponding optimal pH ranges for hydrogen and oxygen evolution. More specifically, our results indicate that GaN stands out among these semiconductors as the most promising candidate for the overall water splitting, with the potential of further improvement through alloying. With the surface coverage, our computational analysis brings a new descriptor that is currently beyond experimental reach.

KEYWORDS: water splitting, semiconductor-water interface, acidity constant, surface coverage, band alignment, thermodynamic integration, molecular dynamics simulation



INTRODUCTION

Despite the extensive attention from the scientific community^{1–10} and the tremendous efforts that have been devoted,^{11–17} the efficiency of heterogeneous photocatalytic water splitting is still by and large unsatisfactory.^{1,18} This precludes any large-scale commercial application of this otherwise promising technology for the production of clean fuel.¹⁸ One of the key features currently hindering any prospective use of this process is the lack of an efficient photocatalyst material.¹⁹

In principle, any semiconductor that is stable in an aqueous environment and capable of harvesting solar light could be a photocatalyst for the water splitting reaction, thus providing a plethora of candidate materials. This enormous set might be reduced by considering several supplementary requirements for the ideal catalyst, such as a favorable alignment of the band edges, with respect to the redox levels of liquid water,²⁰ a long lifetime and high mobility of the charge carriers,^{21–23} a high resistance to corrosion, a strong defect tolerance, and a large ensuing photovoltage.²⁴ Another factor that is equally important but that has received less attention is the propensity to dissociate water molecules upon surface absorption.^{25,26} The spontaneous occurrence of dissociated water molecules in the form of ionic species like H⁺ and OH⁻ under near-neutral conditions is certainly beneficial for promoting hydrogen or

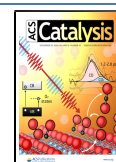
oxygen evolution,²⁷ and allows one to avoid extremely acidic or alkaline solutions, which could more easily induce electrode degradation. However, in practice, all of these properties cannot be tested experimentally for so many candidate materials.

Therefore, since the first investigations of heterogeneous water splitting,¹¹ computational chemistry and physics have been used to disentangle some of the phenomena that are relevant to the efficiency of this process and to introduce an element of design in the systematic exploration of candidate materials.^{19,25,26,28–44} Because of the recent development of advanced electronic-structure methods, excellent results have been achieved in the calculation of the band gap of semiconductors^{45–49} as well as in the alignment of the band edges at water/semiconductor interfaces.^{20,25,28,37} Based on simplified computational protocols, theoretical screenings of candidate materials have been deployed^{19,30–33} in order to define smaller sets of possibly promising photocatalysts with

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appropriate band gaps and band edges favorably aligned to the redox levels of hydrogen reduction and water oxidation.²⁰ Furthermore, the calculation of the overpotentials associated with the water oxidation reaction has been made possible both by means of simplified interface models^{29,41,50–53} and, more recently, by means of more realistic semiconductor/water interfaces in a few cases.^{41,54}

In this framework, the theoretical description of physical processes occurring at semiconductor/water interfaces is complicated by their multifaceted nature, which is dependent on various factors, e.g., the pH of the aqueous solution in which the material is immersed and possible reconstructions and defects at the surface.^{26,35} Therefore, simplified computational protocols in which such effects are completely ignored are likely to miss important physical aspects, thus affecting and possibly invalidating the achieved results. While the simultaneous inclusion of all effects in a single simulation remains currently beyond reach, it has recently been shown that theoretical approaches are at least capable of describing the acid–base chemistry and reactivity of pristine semiconductor/water interfaces.^{25,26} However, in order to identify the characteristics of the ideal photocatalyst, it is necessary to enable a more extensive screening, in which semiconductor/water interfaces are modeled at the atomistic level and additional criteria besides band gaps and band edge positions are considered.

Here, we study the acid–base chemistry and reactivity of eight different semiconductors at the interface with liquid water: GaAs(110), GaP(110), GaN(10 $\bar{1}$ 0), CdS(10 $\bar{1}$ 0), ZnO(10 $\bar{1}$ 0), SnO₂(110), rutile TiO₂(110) (r-TiO₂), and anatase TiO₂(101) (a-TiO₂), building upon previously determined interfacial structures and band alignments at these semiconductor/water interfaces.²⁸ By combining extensive *ab initio* molecular dynamics (MD) simulations with a Grand Canonical formulation of adsorbates at the semiconductor/water interface,^{26,55} we determine the pH at the point of zero charge (pH_{PZC}) and find excellent agreement with the available experimental characterization²⁸ for all considered semiconductors. By calculating the acidic constant (pK_a) of the individual adsorption sites at the interface, we are capable of investigating for each material the stability of adsorbed protons, hydroxyl ions, and water molecules at different pH values. Furthermore, we align the band edges of the considered semiconductors at the interface with water by applying a scheme based on the lineup of the potential and on a computational standard hydrogen electrode.^{25,28,56} By combining the acid–base chemistry with the alignment of the band edges, with respect to the redox levels pertaining to the water splitting reaction, we examine the potential of the investigated semiconductors to act as efficient photocatalysts and identify the optimal pH ranges of operation for hydrogen and oxygen evolution. Among the considered materials, our approach identifies GaN as the most promising photocatalyst for achieving overall water splitting under near-neutral conditions and indicates the possibility of achieving further improvement through alloying.

METHODS

In this work, we determine site-specific acidity constants pK_a at semiconductor/water interfaces within a Grand Canonical formulation of adsorbates.^{26,55} The formulation has been generalized to include molecular, dissociative and mixed adsorption modes, as described in [section S1 of the Supporting](#)

[Information \(SI\)](#). In this method, deprotonation free energies of adsorbed protons and water molecules are calculated through the thermodynamic integration method (see [section S3 of the SI](#)), which involves both MD simulations of neutral interfaces as well as MD simulations of interfaces with charged adsorbates (see [section S2 of the SI](#)). As far as the neutral interfaces are concerned, we take advantage of previously generated MD trajectories for equilibrated semiconductor/water interfaces²⁸ and calculate the relevant energy differences upon deprotonation. The MD simulations of the charged species are run on purpose in the present study and then used for the calculation of the thermodynamic integrals.

The MD simulations used in this work are performed with a semilocal functional, which accounts for nonlocal van der Waals interactions (r-VV10).^{57,58} The parameter *b* of the rVV10 functional is set to the value of 9.3, in order to correctly reproduce the density and the structural properties of liquid water.⁵⁹ All the relevant energy differences associated with the MD trajectories are first obtained consistently within the same semilocal scheme. The deprotonation energies corresponding to the same structural configurations are then also evaluated at the hybrid functional level. For this, we use the hybrid functional h-rVV10, which combines the PBE0 hybrid functional with the rVV10 description of nonlocal van der Waals interactions.⁶⁰ In this hybrid functional, the fraction *α* of Fock exchange is set to 0.40 and the *b* parameter of rVV10 is set to 5.3, as these parameters have been found to give a good description of the density and the structural properties of liquid water.⁶⁰ Accordingly, the values of pH_{PZC} and the acidity constants (pK_a) at the studied semiconductor/water interfaces are determined at both levels of theory (see [section S4 of the SI](#)). Our results show that the hybrid functional yields pH_{PZC} values that are in much better agreement with experimental results than the semilocal functional. Notably, the pK_a values are found to be even more sensitive to the adopted level of theory, with the semilocal functional significantly overestimating the pK_a of protons adsorbed on specific nonmetal surface sites, such as As, P, and S (see [section S4 of the SI](#)). Consequently, the presentation in the following focuses on the results obtained at the hybrid functional level and the reader is referred to [section S4 of the SI](#) for a discussion of the semilocal results. A more extensive description of the applied methodologies is given in [section S3 of the SI](#).

RESULTS AND DISCUSSIONS

The pH_{PZC} values obtained at the hybrid-functional level are reported in [Figure 1a](#) for comparison with experimental estimates.²⁸ The agreement with the measured values is excellent, as demonstrated by the mean average error (MAE) of only 0.75 pH unit (see [section S4 of the SI](#)). This corresponds to an energy error of <0.05 eV, well within the typical accuracy of the hybrid-functional methods applied here (0.1–0.2 eV). In particular, for GaAs, GaP, and a-TiO₂, the calculations have been performed using two different adsorption modes at the interface: (i) a molecular (*m*) mode, in which water molecules are adsorbed on the metal sites *M* (e.g., Ga and Ti atoms), and (ii) a dissociative (*d*) mode, in which hydroxyl ions are adsorbed on the metal sites *M* while protons are attached to the nonmetal sites *A* (e.g., As, P, and O atoms). The consideration of two interface models for these semiconductors is motivated by the fact that both the *d* or *m* modes appear to be stable on the time scales of our MD simulations, while this is not necessary for the other

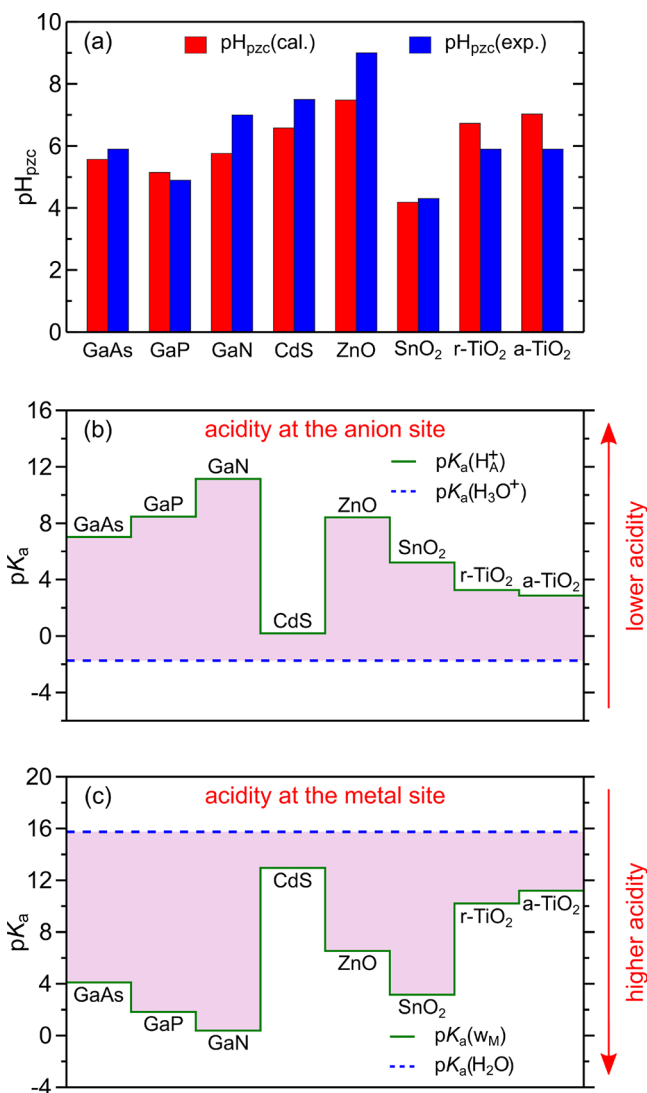


Figure 1. (a) Calculated values of pH_{pzc} (red bars) at various semiconductor/water interfaces, compared with experimental estimates taken from ref 28 (blue bars). (b) pK_a of the proton (H_A^+) adsorbed on a nonmetal site A of the surface (e.g., As, P, N, S, and O atoms). (c) pK_a for the water molecule (w_M) adsorbed on a metal site M of the surface (e.g., Ga, Cd, Zn, Sn, and Ti atoms). In panels (b) and (c), the blue dashed lines indicate the pK_a for aqueous hydronium ions and water molecules, respectively. All values are reported in units of pH.

semiconductors for which the MD runs show a rapid conversion to a unique type of adsorption mode, irrespective of the starting configuration.²⁸ Nevertheless, it is reassuring to find that the pH_{pzc} calculated with *m* and *d* models differ negligibly (i.e., by <0.6 pH units, see section S4 of the SI).

The remarkable accuracy achieved for the values of pH_{pzc} enables us to further analyze the acid–base chemistry of the water/semiconductor interfaces under consideration. In particular, we investigate the acidic constants of adsorbed protons on the nonmetal sites A [$pK_a(H_A^+)$] and of adsorbed water molecules on the metal sites M [$pK_a(w_M)$] for each semiconductor surface. The respective acidic constants from our calculations are illustrated in Figures 1b and 1c, where they are compared with the acidic constant of the aqueous hydronium cation [$pK_a(H_3O^+) = -1.74$, by definition] and with that of an aqueous water molecule [$pK_a(H_2O) = 15.74$,

respectively. For all the interfaces, we find that the acidity of the adsorbed proton is noticeably weaker than that of the aqueous hydronium cation. However, we can distinguish two different behaviors. Oxides and sulfides, with the exception of ZnO, show a moderately acidic adsorbed proton. In particular, a $pK_a(H_A^+)$ value as low as 0.19 is obtained for CdS. Anatase and rutile show similar properties with values of $pK_a(H_A^+)$ close to 3, while a higher alkalinity is observed for SnO₂ [$pK_a(H_A^+) = 5.20$] and, more remarkably, for ZnO [$pK_a(H_A^+) = 8.42$]. At variance, the nonmetal sites A of the III–V semiconductors are rather alkaline with values of $pK_a(H_A^+)$ up to 11.14 for GaN. It is interesting to point out that, comparing GaN, GaP, and GaAs, we observe an increasing acidity of the proton site going from N to As, in agreement with the decreasing electro-negativity.

In Figure 1c, the $pK_a(w_M)$ pertaining to the metal sites of the various semiconductors are compared with the corresponding acidic constant of the aqueous water molecule calculated at the same level of theory. III–V semiconductors show the largest differences with $pK_a(w_M)$ values ranging between 0.38 for GaN and 4.10 for GaAs. Since the water molecules are always adsorbed on a Ga surface site in these cases, it is evident that also the surrounding chemical environment, as determined by the nearest neighbors and the surface structure (110 for GaAs and GaP, 1010 for GaN), affect the acidity of the adsorbed water molecules. For oxides and sulfides, we observe alkaline $pK_a(w_M)$ values for CdS and for the two polymorphs of TiO₂. By contrast, the acidity of adsorbed water molecules is noticeably increased for ZnO [$pK_a(w_M) = 6.54$], and even more so for SnO₂ [$pK_a(w_M) = 3.16$].

Overall, the calculated data should be interpreted taking into account the different electronegativities of the surface sites but also the chemical environment at the surface. For example, while CdS and ZnO have a very similar surface structure, the calculated values of both $pK_a(H_A^+)$ and $pK_a(w_M)$ are completely different, because of the intrinsic difference in reactivity of the surface sites. Similarly, we observe that surface O sites of different semiconductor surfaces can span a large range of values for $pK_a(H_A^+)$. Hence, a clear role should be assigned to the chemical environment at the surface in modulating the acidity of chemically equivalent sites. It is important to underline that the complex interplay between intrinsic reactivity and chemical environment might not be captured by simplified models.

By combining the results achieved for $pK_a(H_A^+)$ and $pK_a(w_M)$, it is also possible to determine the natural tendency of a given semiconductor surface to induce water dissociation. This is done by defining the free energy of dissociation for adsorbed water molecules (ΔA_d):^{26,61}

$$\Delta A_d = \ln 10 k_B T [pK_a(w_M) - pK_a(H_A^+)] \quad (1)$$

where k_B is the Boltzmann constant and T is the temperature. Negative values of ΔA_d indicate exothermic dissociation of the adsorbed water molecules, while positive values make the process unfavorable, thus favoring adsorption of molecular water. We remark that through the calculation of ΔA_d the thermodynamic integration method allows one to identify the most stable adsorption mode, even when regular MD fail to overcome the energy barriers separating different surface configurations.²⁸ In Figure 2, we illustrate the calculated values of ΔA_d for the eight studied semiconductors. Again, we can broadly distinguish two groups of semiconductors. III–V semiconductors favor the dissociation of the H₂O molecules

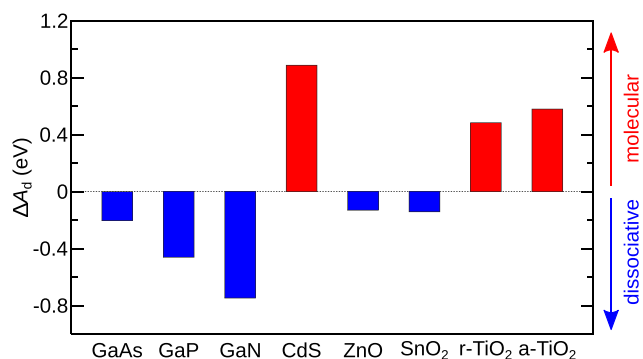


Figure 2. Calculated free energy of dissociation for adsorbed water molecules on various semiconductor surfaces. Red (blue) bars indicate that the molecular (dissociative) adsorption mode is favored.

with a clear trend toward more favorable dissociation as the electronegativity of the anion increases along the series GaAs, GaP, and GaN. At variance, oxides and sulfides appear to favor molecular adsorption of water molecules on their pristine surfaces, with the exception of SnO₂ and ZnO, which show moderately negative values for ΔA_d (approximately −0.15 eV). This result is consistent with the outcome of MD simulations for these two interfaces,²⁸ for which the coexistence of molecular and dissociated water molecules is observed. For both a-TiO₂ and r-TiO₂, we find a ΔA_d value of ∼0.5 eV, indicating that the water molecules are molecularly adsorbed on their pristine surfaces. Therefore, the present method provides an unequivocal description of the surface adsorption mode, improving upon straightforward MD simulations, which were unable to sort out the issue in the case of a-TiO₂(101).²⁸ In addition, we note that the calculated energetic preference is remarkably higher than the experimentally measured energy difference of 0.035 eV between a molecularly adsorbed and a dissociatively adsorbed water molecule on the r-TiO₂(110) surface exposed to vacuum.⁶² This discrepancy should be attributed to the solvent, which stabilizes the adsorbed water molecules in the simulations.

The calculated acidity constants do not only provide insight into the physicochemical properties of the semiconductor/water interfaces, but they also allow for a detailed description of the pH-dependent surface chemistry of such interfaces. This is achieved by constructing logarithmic diagrams of concentration, commonly employed for weak acids in aqueous solution, and recently extended to semiconductor/water interfaces.²⁶ In Figure 3, we illustrate this powerful instrument for visualizing the acid–base properties of the interfaces studied. However, it should be realized that inaccuracies of ∼1–2 pH units for pK_a(H_A⁺) and pK_a(w_M) may lead to sizable variations of equilibrium concentrations, because of the exponential dependence of such concentrations on energy (see section S1 of the SI).

The concentration diagrams for GaAs, GaP, and GaN are rather similar, all showing a preference for dissociative water adsorption at pH_{PZC}. In the case of GaAs(110) [Figure 3a], the ratio between the concentrations of dissociatively and molecularly adsorbed water at pH_{PZC} is found to be close to 30:1, implying that only ∼3% of the adsorbed water retains its molecular form. This is consistent with in situ near-ambient pressure XPS studies revealing dissociative adsorption of water at the GaAs/water interface.⁶³ For GaP(110) [Figure 3b] and GaN(1010) [Figure 3c], the concentration of ionic species

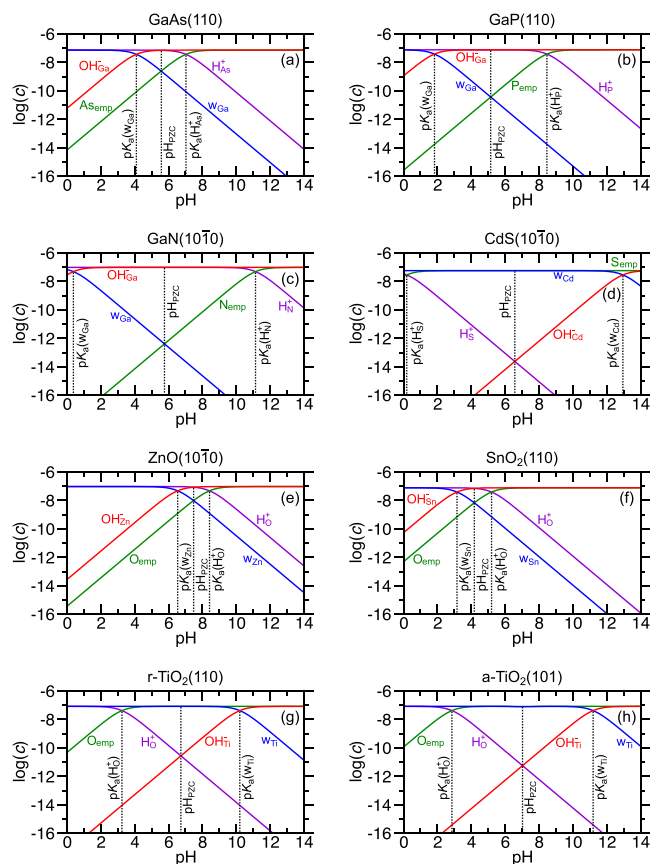


Figure 3. Acid–base logarithmic diagrams for the coverage of pristine (a) GaAs(110), (b) GaP(110), (c) GaN(1010), (d) CdS(1010), (e) ZnO(1010), (f) SnO₂(110), (g) r-TiO₂(110), and (h) a-TiO₂(101) surfaces in an aqueous environment, as calculated at the h-rVV10 level of theory. The concentration values *c* are expressed in units of mol/dm².

exceeds that of molecular adsorption by over 3 orders of magnitude at pH_{PZC}, indicating that the model showing complete dissociation is representative of the real interface.²⁸ Under near-neutral conditions, at which an ideal water-splitting plant should operate,¹ ∼100% of the surface Ga sites are passivated by hydroxyl ions for these Ga-based semiconductors. Hence, the water oxidation reaction on these surfaces will proceed through the reaction mechanism occurring under alkaline conditions (i.e., through the oxidation of the adsorbed hydroxyl ions),²⁷ which is kinetically more favorable and faster than the reaction mechanism occurring under acidic conditions (i.e., the dehydrogenation of the adsorbed water molecules).²⁷ At pH ∼7, we find that ∼52% of the surface As sites are protonated, while the respective percentages increase to ∼97% and 100% for surface P and N sites. In the case of GaAs, we observe a rather narrow pH window (4.1 < pH < 7.0), within which protons and hydroxyl ions are the dominant adsorbed species. The corresponding pH windows are wider for GaP and GaN, where they extend from 1.8 to 8.5 and from 0.4 to 11.1, respectively. These large pH windows are particularly desirable for the overall photocatalytic water splitting reaction, for which adsorption of both ionic species is realized without enforcing extremely acidic (for protons) or alkaline (for hydroxyl ions) conditions. For pH values of <4.1 for GaAs, <1.8 for GaP, and <0.4 for GaN, molecular water becomes the dominant adsorbate and

the water oxidation reaction would then mainly proceed through the dehydrogenation of adsorbed water molecules, for which the mechanism is slow and kinetically unfavorable. This explains why the water-splitting efficiency at a GaN photoanode is poorer in the presence of electrolytes such as H_2SO_4 than electrolytes such as KOH or NaOH.⁶⁴

The diagrams for ZnO [Figure 3e] and SnO_2 [Figure 3f] highlight their peculiar surface coverage, by which protons and hydroxyl ions simultaneously dominate the adsorbed species only in a rather narrow pH range ($6.5 < \text{pH} < 8.4$ for ZnO and $3.2 < \text{pH} < 5.2$ for SnO_2). For these materials, we observe at pH_{PZC} the coexistence of ionic species, unoccupied surface O sites, and molecularly adsorbed water, consistent with previous MD simulations, indicating the occurrence of a mixed adsorption mode.²⁸ At $\text{pH} \sim 7$, the surface coverages of ZnO and SnO_2 differ noticeably. For ZnO, nearly three out of four surface Zn sites are passivated by hydroxyl ions and the percentage of protonated surface O sites is as high as 96%, showing favorable conditions for the overall water splitting reaction. Instead, such conditions are less convenient for SnO_2 . Although all surface Sn sites are also favorably covered by hydroxyl groups, the fraction of adsorbed protons becomes negligible. This adsorption mode under near-neutral conditions supports SnO_2 as a good photocatalyst for oxygen evolution rather than for the overall water splitting reaction. For making SnO_2 more suitable for the latter reaction, it would be preferable to operate under slightly acidic conditions (e.g., at $\text{pH} \sim 4$).

The situation is completely different in the case of CdS [Figure 3d], for which the concentrations of ionic adsorbates at pH_{PZC} are ~ 6 orders of magnitude lower than that of molecularly adsorbed water. This result is fully consistent with the outcome of previous MD simulations, where it has been found that the molecular adsorption mode is spontaneously realized.²⁸ We notice that the fraction of adsorbed protons and hydroxyl ions is negligible over a pH interval ranging from 1 to 12. Therefore, CdS would operate as a poor photocatalyst for the overall water splitting reaction, as the reduction of protons on its surface is largely adsorption-limited. To achieve overall water splitting, one should operate under extremely acidic conditions ($\text{pH} < 1$), where adsorbed protons begin to appear, but even in this case, water oxidation would proceed through the slow and kinetically unfavorable mechanism involving adsorbed water molecules. Only when $\text{pH} > 13$, the surface is prevalently hydroxylated and the oxidation could proceed through the more favorable mechanism involving the adsorbed hydroxyl ions. Hence, the present analysis indicates that CdS is not a suitable photocatalyst for either the hydrogen reduction or the water oxidation reaction.

The concentration diagrams for the two phases of TiO_2 [Figures 3g and 3h] are similar to that of CdS, with molecular adsorption dominating over a large pH range ($3.3 < \text{pH} < 10.2$ for r- TiO_2 and $2.9 < \text{pH} < 11.2$ for a- TiO_2). At pH_{PZC} , the concentrations of ionic species are at least 4 orders of magnitude lower than that of molecularly adsorbed water. H^+ and OH^- ions are found in significant concentrations only under acidic and alkaline conditions, respectively. Such conditions are not convenient for the operation of an overall water splitting device. At near-neutral pH, the hydrogen evolution would be hindered by the absence of adsorbed protons and the oxygen evolution reaction would occur through the slow mechanism associated with the dehydrogenation of water molecules,²⁷ while the kinetically more favorable

mechanism involving oxidation of adsorbed hydroxyl ions²⁷ would be inhibited. The latter tendency could be reversed only at highly alkaline values of pH, where one would, however, face the issue of surface degradation. This result is consistent with the experimental observation that rutile TiO_2 powder shows low activity for the overall water splitting at pH 2, because of the extremely low rate of oxygen evolution.⁶⁵ Furthermore, it has experimentally been found that r- TiO_2 yields the highest photocatalytic performance at pH 5.5.⁶⁵ This observation can be understood as follows. From Figure 3g, we notice that a pH of 5.5 corresponds to the highest value at which some of the O sites at the surface ($\sim 1\%$) are still protonated. Under these acidic conditions, hydroxyl groups do not occur on pristine r- $\text{TiO}_2(110)$ according to our calculations, but such adsorbates could be stabilized by the occurrence of defects at the surface, such as oxygen vacancies, which significantly promote the dissociation of adsorbed water molecules.⁶⁶ The optimal pH value then results from a tradeoff. For more alkaline solutions, the hydrogen evolution is inhibited, because of the lack of adsorbed H^+ , whereas the defect-induced OH^- ions would suffer from the recombination with protons under more acidic conditions, leading, in turn, to the poor efficiency of O_2 evolution.

The adsorption of suitable reactants is surely a precondition for heterogeneous photocatalytic water splitting, but is not sufficient to ensure the efficiency of the process. In fact, a desirable acid–base chemistry of the semiconductor/water interface must also rely on a favorable alignment between the electrochemical energy levels involved in the proton-coupled electron transfer reactions,⁵⁰ namely, the band edges of the semiconductors, which provide the charge carriers, and the redox potentials associated with hydrogen reduction and water oxidation. By combining the band alignment at the semiconductor/water interface with the description of the surface chemistry, one can infer whether the photocatalytic reactions run efficiently.²⁵ Hence, for each semiconductor, we consider an energy level diagram that includes the band edges and the relevant redox levels (cf. Figure 4). We take the band edges as calculated in ref 28 and revised according to the improved estimate of the SHE level proposed in ref 67. Here, we use

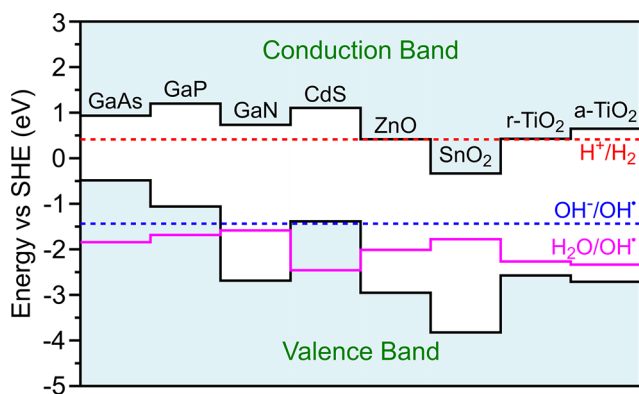


Figure 4. Band edges, together with relevant redox levels (H^+/H_2 in dashed red, OH^-/OH^* in dashed blue, and $\text{H}_2\text{O}/\text{OH}^*$ in solid magenta) at various semiconductor/water interfaces at pH 7, referred to the SHE. We take band edges as calculated at the PBE0(α) level in ref 28 and revised according to the improved estimate of the SHE level reported in ref 67. The redox levels H^+/H_2 and OH^-/OH^* have been calculated in the solution (see section S1 of the SI) and are taken from ref 56.

calculated band edges rather than experimental ones to demonstrate that our theoretical approach is self-standing, but the use of experimentally determined band edges in Figure 4 would not affect any of the relative energy positions.

Since the hydrogen evolution reaction is generally not responsible for slowing down the overall water splitting reaction,⁵⁰ we do not explicitly consider intermediate states associated with surface adsorption and directly focus on the H^+/H_2 redox level in solution, which corresponds to the SHE at pH 0. At variance, in the case of the oxygen evolution reaction, intermediate states adsorbed at the surface are known to play a more critical role, leading to significant overpotentials.⁵⁰ Hence, we focus on the OH^-/OH^\bullet redox level for the oxidation of adsorbed hydroxyl anions and on the H_2O/OH^\bullet redox level for the dehydrogenation of adsorbed water molecules, which represent the first step of the water oxidation process under alkaline and acidic conditions, respectively.²⁷ The associated overpotentials result from the oxygen oxidation chemistry, but generally are also dependent on the specific material under consideration. For the adsorbed hydroxyl anions at pH_{pZC} , we account for the oxygen oxidation chemistry by taking the redox level pertaining to the aqueous hydroxyl ion as the indicative one,⁵⁶ but disregard material-specific differences in the same spirit as for the hydrogen evolution reaction. In the case of $r\text{-TiO}_2(110)$, the oxidation potentials of the OH^-/OH^\bullet level calculated in liquid water⁵⁶ and at the solvated interface^{41,68} differ by <0.05 eV, supporting this way of proceeding. We infer the H_2O/OH^\bullet redox level from a two-step process involving sequentially the deprotonation of the adsorbed water molecule and the oxidation of the hydroxyl ion. Furthermore, we assume ideal conditions in which the band edges of the semiconductors and the relevant redox levels follow a Nernstian behavior, i.e., they move closer to the vacuum level with increasing pH at the rate of 0.059 eV per pH unit. In particular, it is important to remark that the relative positions between the band edges of the semiconductors and the redox levels are not dependent on pH. For a more-detailed discussion of the redox levels, we refer the reader to section S1 of the SI.

As can be seen in Figure 4, the conduction band edges of all the semiconductors studied are favorably aligned with respect to the H^+/H_2 redox level, with the sole exception of SnO_2 , suggesting that these materials are suitable for photocatalytic hydrogen evolution. For the oxidation of water, the valence band edges of GaAs, GaP, and CdS are significantly higher than the redox levels of OH^-/OH^\bullet and H_2O/OH^\bullet , making of these materials poor photocatalysts. The valence band edges of the other semiconductors lie at least 0.3 eV lower than the OH^-/OH^\bullet and H_2O/OH^\bullet levels, implying that these materials are suitable for photocatalytic water oxidation.

For evaluation, in Figure 5, we provide a global overview of the photocatalytic potential of the investigated semiconductors by combining information concerning the surface coverage and the energy level alignment. Considering that highly acidic or alkaline solutions generally degrade the water splitting devices, we focus our attention onto those semiconductors that show significant coverage with ionic adsorbates and favorable alignment under near-neutral conditions ($5 \leq pH \leq 9$). Hence, in Figure 5, the occurrence of blue bars for the ionic adsorbates (H^+ and OH^-) within the yellow stripe signals the possibility of efficient hydrogen and oxygen evolution in the most favorable pH range. In this way, we infer that the Ga-based compounds and ZnO are the most suitable photo-

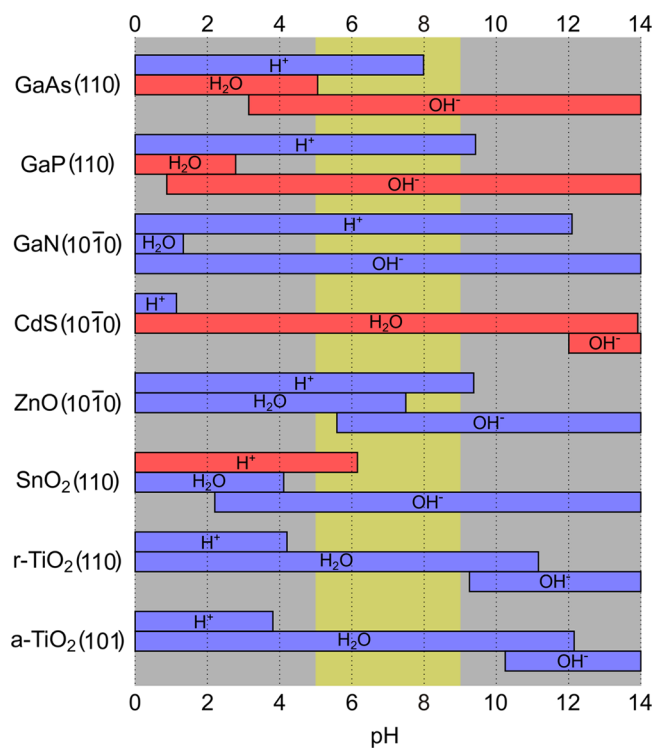


Figure 5. Combined view on the surface coverage and alignment for the various semiconductors. For each adsorbate, the bars indicate the pH range where its surface coverage corresponds to a fraction of 10% or more, and the blue (red) color specifies a favorable (unfavorable) alignment between the band edges of semiconductor and the relevant redox levels. The vertical yellow stripe emphasizes near-neutral conditions with $5 \leq pH \leq 9$.

catalysts for hydrogen reduction, while water oxidation is best achieved with SnO_2 , ZnO, and GaN. Among these semiconductors, GaN is the most promising candidate for the all-in-one reaction showing the largest range of suitable pH values. ZnO stands out as an alternative candidate with a band alignment similar to that of GaN but with a lower coverage of hydroxyl ions.

It is known that the photocatalytic efficiencies of pristine GaN and ZnO are still far from being satisfactory.^{69,70} This is, to a large extent, due to their large band gaps (>3.2 eV), which inhibit the efficient adsorption of solar light. Experimental observations indicate that alloying GaN with ZnO leads to a significant reduction of the band gap, as the result of a slight downward shift of the conduction band edge and of a dramatically upward shift of the valence band edge.^{71,72} For instance, it is sufficient to consider a $(GaN)_{1-x}(ZnO)_x$ alloy with x as small as 0.13 to achieve a band gap decrease to 2.58 eV.⁷³ This is consistent with the GaN–ZnO alloy being a much more efficient photocatalyst than pristine GaN and ZnO, as demonstrated experimentally.^{69,73–87} As for the alignment, there is sufficient margin to preserve the favorable band alignment upon alloying, since the valence band of GaN is found to be lower than the OH^-/OH^\bullet level by as much as 1.25 eV (cf. Figure 4). Our study provides additional insight, shedding light on the surface coverage as a function of pH. From Figure 5, it is reasonable to assume that, under near-neutral conditions, the ionic adsorbates would dominate on the surface of the GaN–ZnO alloy, as also observed in MD simulations performed at the point of zero charge.⁸⁸ This leads to all metal sites and all nonmetal sites at the surface being

passivated by OH^- and H^+ ions, respectively, constituting an ideal surface coverage for the overall water splitting (cf. Figure 3). However, experimental results for the alloy $(\text{GaN})_{0.87}(\text{ZnO})_{0.13}$ indicate that it is necessary to add RuO_2 nanoparticles acting as a co-catalyst to achieve overall water splitting, with the highest activity being obtained at pH 3.⁷³ The co-catalyst is known to operate effectively under acidic conditions by promoting the hydrogen evolution reaction through the adsorption of protons.⁸⁹ Our results then suggest that the oxygen evolution reaction occurs through the OH^- ions adsorbed on the Ga sites, since the Zn sites no longer present these ions under such acidic conditions (cf. Figure 5). These considerations provide a rationale for designing GaN:ZnO alloys with a small content of ZnO.

As an alternative alloying strategy for GaN, the results in Figure 5 suggest partial substitution of N with either As or P. In fact, the valence band edges of GaP and GaAs lie much higher than that of GaN (cf. Figure 4). Hence, a suitable concentration of P and As would also push up the valence band of the alloyed GaN and consequently reduce the band gap. Furthermore, despite the slightly different acidity at the N, P, and As sites, their $\text{p}K_a(\text{H}^+)$ values allow for a large fraction of protons to be adsorbed under near-neutral conditions (cf. Figure 5).

The two polymorphs of TiO_2 also deserve attention, as they both show a favorable band alignment for hydrogen and oxygen evolutions. Nevertheless, their photocatalytic efficiency has remained low⁹⁰ and appears to be hindered, on the one hand, by the low concentration of adsorbed ionic species under near-neutral conditions (cf. Figure 5) and, on the other hand, by the size of their band gaps (>3.0 eV). Although active defect sites have been shown to promote water dissociation,^{66,91,92} the amount of ionic adsorbates is apparently still insufficient to make the reaction viable at a satisfactory rate.^{93,94} Compared to GaN and ZnO, the design of highly efficient catalysts based on TiO_2 for the overall water splitting reaction appears to be more complicated, as it would require not only a significant reduction of the band gap without deteriorating the good alignment of the energy levels, but also a substantial modification of the surface coverage. Nevertheless, nitrogen doping has been extensively deployed for TiO_2 with the motivation of simultaneously narrowing the band gap and inducing a higher surface coverage of ionic species.^{95–98} In an alternative approach, one could turn to nanoparticles of TiO_2 , which possess smaller gaps and favor ionic adsorbates at their higher-energy surfaces.^{99–106} Such surfaces have been demonstrated to be more reactive and to promote electron-transfer processes in dye-sensitized solar cells,¹⁰⁷ thus deserving a more in-depth investigation for water splitting.

CONCLUSIONS

In this work, we present a theoretical formulation for investigating the pH-dependent surface coverage at semiconductor/water interfaces through the use of ab initio molecular dynamics simulations and a Grand Canonical formulation of adsorbates. Our study encompasses eight semiconductors, including GaAs, GaP, GaN, CdS, ZnO, SnO_2 , and rutile and anatase TiO_2 . The present methodology allows us to calculate the acidity of individual adsorption sites at the interface, and consequently to derive the pH value at the point of zero charge (pH_{PZC}), as well as the fraction of dissociated water molecules at the surface. The calculated pH_{PZC} show excellent agreement with their experimental

counterparts, thereby supporting the validity of our formulation. Furthermore, based on the calculated $\text{p}K_a$ for the surface sites, we construct concentration diagrams of the interfacial adsorbates as a function of pH. By combining our results for the surface coverage and the band alignment, we investigate the potential of the considered semiconductors as photocatalysts for hydrogen and oxygen evolution and determine the corresponding pH ranges for optimal operation. Among the investigated semiconductors, our scheme naturally identifies GaN as the most promising candidate for the overall water splitting reaction and additionally indicates the possibility of achieving further improvement through alloying. The computational approach introduced in our work gives access to the characterization of materials properties that represent invaluable descriptors to identify optimal photocatalyst in the screening of materials. In particular, the site-specific acidic constants and the surface coverage remain at present beyond experimental reach.

ASSOCIATED CONTENT

Supporting Information

The Supporting Information is available free of charge at <https://pubs.acs.org/doi/10.1021/acscatal.0c03006>.

Theoretical formulation for calculating acidity constants of semiconductor surface sites, pH-dependent surface coverage, and redox levels in solution and at semiconductor/water interfaces (Section 1); description of semiconductor/water interfacial models and influence of adsorbates on surface structures (Section 2); description of methods for running MD simulations, calculating deprotonation free energies, and performing electrostatic finite-size and zero-point motion corrections (Section 3); and comparison of pH_{PZC} and $\text{p}K_a$ achieved at semilocal and hybrid functional levels (Section 4) (PDF)

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Notes

The authors declare no competing financial interest.

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